FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE (Rev 2-32) PATENT AND TRADEMARK OFFICE					ATTY, DOCKET NO.: 104561			SERIAL NO.:			
					APPLICANT:				- 6		
INFORMATION DISCLOSURE STATEMENT BY APPLICANT					Man-Wing Tang et al.				2.		
(Use several sheets if necessary)				FILING DATE:			GROUP ART UNIT:		S		
U.S. PATENT DOCUMENTS											
EXAMINER INITIAL	DOCUMENT NUMBER			DATE	NAME	CLA	ıss	SUBCLASS	FILING IF APPRO		
67	US 4,401	US 4,401,556 B1			Bezman et al.		8	111	04/12/82		
	US 4,830	US 4,830,643 B1			Sassa et al.	05	55	316	07/13/88		
	US 4,869	US 4,869,803 B1			Ward	20	8	046	05/23/88		
	US 4,886	US 4,886,769 B1			Kuma et al.	50	2	062	06/10/88		
	US 5,518	US 5,518,977 B1			Dunne et al.	50	2	068	06/05/95		
	US 5,585	US 5,585,145 B1			Maier-Laxhuber et a	t al. 427 380		380	02/17/95		
	US 5,593	US 5,593,482 B1			Dauber et al.	09	6	135	04/07/92		
	US 5,650	US 5,650,221 B1			Belding et al.	44	2	417	07/06/95		
	US 5,702	US 5,702,503 B1			Tse Tang	09	5	045	06/03/94		
	US 5,911,	US 5,911,937 B1			Hekal	26	4	255	03/05/96		
	US 6,130,	US 6,130,263 B1			Hekal	52	1	050	03/05/97		
	US 6,214,	US 6,214,095 B1			Logan et al.	09	096 147		07/06/99		
lee	US 6,238,467 B1			05/01	Azarian et al.	09	096 135		09/24/99		
FOREIGN PATENT DOCUMENTS											
	DOCUMENT NUMBER	DATE	со	UNTRY	NAME	CLASS		SUBCLASS	TRANSL	ATION	
									YES	NO	
ee	SU 1763000 A1	09/92	USSR		Fedorov et al.				Х		
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)											
Article "The Effect of Vapor Phase Chemicals on Head/Disk Interface Tribology" byM.S. Jesh and P.R. Segar, <i>Tribology Transactions</i> , Vol. 42 (1999),2, pages 310-316.											
Atlas of Zeolite Structure Types by W.M. Meier and D.H. Olson, issued by the Structure Commission of the International Zeolite Association, (1987), pages 53-54 and 91-92.											
EXAMINER PRINCIPLE DATE CONSIDERED / 2007											

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.